Articulation between fundamental questions and their applications in laboratories in the the field of accelerators

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www.youtube.com/watch?v=qVO65x2IGbk

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Laser Plasma Accelerators : Outline

Introduction : context and motivations

Injection in a density gradient

Manipulating the longitunal momentum

Manipulating the transverse momentum

Conclusion and perspectives

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Fundamental Research





Industrial Market for Accelerators

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Application	Total syst. (2007) approx.	System sold/yr	Sales/yr (M\$)	System price (M\$)
Cancer Therapy	9100	500	1800	2.0 - 5.0
Ion Implantation	9500	500	1400	1.5 - 2.5
Electron cutting and welding	4500	100	150	0.5 - 2.5
Electron beam and X rays irradiators	2000	75	130	0.2 - 8.0
Radio-isotope production (incl. PET)	550	50	70	1.0 - 30
Non destructive testing (incl. Security)	650	100	70	0.3 - 2.0
Ion beam analysis (incl. AMS)	200	25	30	0.4 - 1.5
Neutron generators (incl. sealed tubes)	1000	50	30	0.1 - 3.0
Total	27500	1400	3680	



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The linear wakefield regime: GV/m electric field

The laser wake field : broad resonance condition $\tau_{\text{laser}} \sim \pi/\omega_p$ with $\omega_p \sim n_e^{1/2}$ i.e. $\lambda_p \sim 1/n_e^{1/2}$

electron density perturbation & longitudinal wakefield



The non-linear wakefield regime : 100's GV/m electric field



RF Cavity



Plasma Cavity



1 m => 100 MeV Gain Electric field < 100 MV/m

Electric field > 100 GV/m

Non Linear Wakefield V. Malka *et al.*, Science **298**, 1596 (2002)

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UMR 7639



The Non Linear Regime





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Laser Plasma Accelerator: Non linear regime

Electric field components : Longitudinal and Transverse



Linear accelerating gradient



Linear Focusing gradient



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«Salle Jaune Laser»: Home made laser

2 Joules in 2 laser beams of 30 fs duration delivered at 1 Hz

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Density drop => increase of the cavity lenght

the bubble expansion allows electrons injection and energy gain.

Sharp density ramp is requires to localize the injection and reduce the energy spread !

[Schmid et al., 2010; Buck et al., 2013]

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Injection in a sharp density gradient



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the bubble expansion allows electrons injection and energy gain.

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Injection in a sharp density gradient



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Density drop => increase of the cavity lenght

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Injection in a sharp density gradient





laser

Density drop => increase
of the cavity lenght

the bubble expansion allows electrons injection and energy gain.



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Sharp density ramp is requires to localize the injection and reduce the energy spread!



Injection in a shock front : principle



Injection in a shock front : pur helium gas



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Injection in a shock front : pur helium gas



Electron energies is controlled by the position of the blade

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Injection in a shock front : helium/nytrogene mixture

(a)

He + N

(b)

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He

Combinaison of two injection method (shock and ionization) to generate better beam quality with better stability



Thaury C., Guillaume E. et al., Scientific Reports 5 (2015)

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Overcoming the dephasing limit

since the laser group velocity is < c, when electrons energy is getting $\sim c$ they dephase

electrons reach the center of the cavity and start to be deccelerated



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OO

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OO









The reduction of the bubble size at the right position by increasing suddently the density resets the electrons phase. Electrons can start again

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to gain energy.



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|OO|

↓Πe

Overcoming the dephasing limit





The reduction of the bubble size at the right position by increasing suddently the density resets the electrons phase.

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|OO|

⊾Πe



Overcoming the dephasing limit





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|OO|

⊾Ne

Overcoming the dephasing limit: experimental set-up







Overcoming the dephasing limit: results

Wafer silicium 500 µm

The density transition is controlled by changing the wafer position



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Overcoming the dephasing limit: experimental results & simulations

Calder-Circ PIC Simulations

Experiment



Energy boost of a mono-energetic e-beam



E. Guillaume et al., PRL 115 (2015)

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Manipulating the p_{\perp} momentum : emittance definition



electrons beam emittance : ε_{rms} $\langle x^2 \rangle \langle x'^2 \rangle - \langle xx' \rangle^2$ $\varepsilon_{rms} =$ \mathcal{X} transverse beam size divergence emittance is typical transverse size of the e-beam $< 1 \, \mu m$ dominated by the typical divergence of the e-beam : ~ 4 mrad divergence too large for example for some applications (FEL, ...)

Goal :

reduce the divergence of the beam by manipulating the transverse phase space







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Manipulating the p_ momentum : experimental set-up

Acceleration stage

Laser beam:

0.9 J, 28 fs, 12 microns FWHM Focused with a 1 m OAP at the entrance of a 3 mm gas jet $n_1 = 9.2 \times 10^{18} \text{ cm}^{-3}$

Focusing stage

1 mm nozzle with variable n_2 Variable Ld







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Manipulating the p_{\perp} momentum : demonstration of the laser plasma lens



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By improving the control of the electron motion with intense lasers one can shape the electric field and manipulate the beam properties in the phase space.

Laser Plasma Accelerators have made significant progresses delivering stable, reliable high quality and high current e-beams.

Applications in medicine (radiotherapy, cancer imaging, security) are almost here.

V. Malka et al., Nature Physics 4 (2008), V. Malka Phys. of Plasma 19, 055501 (2012) E. Esarey et al. , Rev. Mod. Phys. 81 (2009), S. Corde et al., Rev. Mod. Phys. 85 (2013)

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Open positions for laser engineer and laser technician and for post-doc

ERC (Paris & X-five & XMED & VERSATILE), Charpac/Laserlab3 & ANAC2/Eucard2

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